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FIRST NAMED INVENTOR APPLICATION NO. FILING DATE ATTORNEY DOCKET NO. CONFIRMATION NO. G0228 09/955,517 09/18/2001 8552 Cyrus E. Tabery EXAMINER 7590 02/15/2005 HASSANZADEH, PARVIZ Himanshu S. Amin Amin & Turocy, LLP ART UNIT PAPER NUMBER National City Center 1900 E. 9th Street, 24th floor 1763

DATE MAILED: 02/15/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		NC	
	Application No.	Applicant(s)	
Office Action Summary	09/955,517	TABERY ET AL.	
	Examiner	Art Unit	
	Parviz Hassanzadeh	1763	_
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet wit	h the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a re oly within the statutory minimum of thirty will apply and will expire SIX (6) MONT te, cause the application to become ABA	ply be timely filed (30) days will be considered timely. HS from the mailing date of this communic	≃ation.
Status			
1)⊠ Responsive to communication(s) filed on 19 L	December 2004.		
	s action is non-final.		
3) Since this application is in condition for allowa	ance except for formal matte	rs, prosecution as to the merit	ts is
closed in accordance with the practice under	Ex parte Quayle, 1935 C.D.	11, 453 O.G. 213.	
Disposition of Claims			
4)⊠ Claim(s) <u>1,2 and 4-26</u> is/are pending in the ap	plication.		
4a) Of the above claim(s) 15-24 is/are withdra	wn from consideration.		
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1,2,4-14,25 and 26</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/o	or election requirement.		
Application Papers			
9) The specification is objected to by the Examine	er.		
10) The drawing(s) filed on is/are: a) acc		y the Examiner.	
Applicant may not request that any objection to the	• •	•	
Replacement drawing sheet(s) including the correct	ction is required if the drawing(s	i) is objected to. See 37 CFR 1.12	21(d).
11)☐ The oath or declaration is objected to by the E	= :		
Priority under 35 U.S.C. § 119			
12) ☐ Acknowledgment is made of a claim for foreign	n priority under 35 U.S.C. &	119(a)-(d) or (f)	
a) ☐ All b) ☐ Some * c) ☐ None of:	r priority ariable ob o.o.o. 3	110(4) (4) 01 (1).	
1. Certified copies of the priority documen	ts have been received.		
2. Certified copies of the priority documen		plication No	
3. Copies of the certified copies of the price)
application from the International Burea	• • • •		
* See the attached detailed Office action for a list	t of the certified copies not re	eceived.	
AMarkonardo			
Attachment(s) 1) Notice of References Cited (PTO-892)		(DTO 440)	
2) Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)		mmary (PTO-413) /Mail Date	
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date		ormal Patent Application (PTO-152)	
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DETAILED ACTION

Response to Arguments

In view of the Appeal Brief filed on 12/9/04, PROSECUTION IS HEREBY REOPENED. New grounds of rejections are set forth below.

To avoid abandonment of the application, appellant must exercise one of the following two options:

- (1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37 CFR 1.113 (if this Office action is final); or,
 - (2) request reinstatement of the appeal.

If reinstatement of the appeal is requested, such request must be accompanied by a supplemental appeal brief, but no new amendments, affidavits (37 CFR 1.130, 1.131 or 1.132) or other evidence are permitted. See 37 CFR 1.193(b)(2).

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- I. Claims 1, 2, 4-14, 25 and 26, drawn to an apparatus (combination), classified in class 156, subclass 345.24.
- II. Claims 15-20, drawn to an apparatus (subcombination), classified in class 356, subclass 355.
- III. Claims 21-24, drawn to method, classified in class 216, subclass 60.

 The inventions are distinct, each from the other because of the following reasons:

Art Unit: 1763

Inventions I and II are related as combination and subcombination. Inventions in this relationship are distinct if it can be shown that (1) the combination as claimed does not require the particulars of the subcombination as claimed for patentability, and (2) that the subcombination has utility by itself or in other combinations (MPEP § 806.05(c)). In the instant case, the combination as claimed does not require the particulars of the subcombination as claimed because the subcombination is a system for monitoring the profile of an aperture and includes a measuring system based on a light reflected from the aperture whereas in the combination the analysis component measures a feature parameter based on a light reflected and/or refracted from the feature and the measured parameter is used by a driving component that controls a mask creating component, that is, the analysis component is coupled to a mask creating component. The subcombination has separate utility such as for measuring profile of apertures on a phase shift mask disposed outside of a mask creating system (ex-situe) or for measuring features of a grating system.

Inventions I, II and III are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case the apparatus can be used for creating a grating system rather than a phase shift mask.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Application/Control Number: 09/955,517 Page 4

Art Unit: 1763

During a telephone conversation with John Ling on 2/10/05 a provisional election was made without traverse to prosecute the invention of Group I, claims 1, 2, 4-14, 25 and 26.

Affirmation of this election must be made by applicant in replying to this Office action. Claims 15-24 are withdrawn from further consideration by the examiner, 37 CFR 1.142(b), as being drawn to a non-elected invention. It is further noticed that Claims 21-24 have been withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected method, there being no allowable generic or linking claim. Election was made without traverse in Paper No. 5.

Claim Objections

Claim 1 is objected to because of the following informalities: in the last paragraph of claim 1, line 3, it is suggested to change "the driving system" to "the driving component" as recited in line 4 of the claim. Appropriate correction is required.

Claims 7 and 14 are objected to under 37 CFR 1.75 as being a substantial duplicate of claim 4; similarly claims 8 and 13 are objected to under 37 CFR 1.75 as being a substantial duplicate of claim 5. When two claims in an application are duplicates or else are so close in content that they both cover the same thing, despite a slight difference in wording, it is proper after allowing one claim to object to the other as being a substantial duplicate of the allowed claim. See MPEP § 706.03(k).

Double Patenting

Art Unit: 1763

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1, 2, 4-14, 25 and 26 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-3 and 8 of U.S. Patent No. 6,562,248 B1. Although the conflicting claims are not identical, they are not patentably distinct from each other because claims are directed to a phase shift mask creating system using a measuring system to monitor and control the features during the mask creating features.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1, 2, 4-14, 25 and 26 are rejected under 35 U.S.C. 102(e) as being anticipated by Subramanian et al (US Patent No. 6,562,248 B1).

The applied reference has a common inventor with the instant application. Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 102(e) might be overcome either by a showing under 37 CFR 1.132 that any invention disclosed but not claimed in the reference was derived from the inventor of this application and is thus not the invention "by another," or by an appropriate showing under 37 CFR 1.131.

Subramanian et al teach (Fig. 1) a system for creating a complimentary phase shift mask comprising:

a mask creating component (etching system) 16 operable to create features 12 in a mask 14;

a measurement component 18 operable to measure the shape, depth and/or width of the apertures 12 created in the mask 14, the measurement component 18 includes a detection system for detecting the reflected and/or diffracted light; and

a control system 17 operatively coupled to the etching system 16 and the measurement component 18, the control system 7 is programmed and/or configured to control the etching system 16 in accordance with the measured characteristic of the features (column 7, line 10 through column 8, line 48, column 9, line 11 through column 10, line 65).

Further regarding claims 1, 25 and 26: the complimentary phase shift mask and alternating aperture phase shift mask are considered the same or obvious variation of each other and the apparatus as disclosed able is inherently capable of being used for creating either of the phase shift mask. It is also noticed that claims 26 simply recites a phase shift mask.

Art Unit: 1763

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. McNeil et al (US Patent No. 5,164,790) teach a scatterometer configured for measuring a characteristic of features on a mask or grating.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Parviz Hassanzadeh whose telephone number is (571)272-1435. The examiner can normally be reached on Tuesday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (571)272-1439. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Parviz Hassanzadeh Primary Examiner Art Unit 1763 Page 7

February 11, 2005